

L Number	Hits	Search Text	DB	Time stamp
2	1392	438/585,592,595.ccls.	USPAT	2002/06/24 15:34
3	625	438/596,618.ccls.	USPAT	2002/06/24 15:34
4	1294	438/622,624.ccls.	USPAT	2002/06/24 15:34
5	831	438/652,655.ccls.	USPAT	2002/06/24 15:34
6	427	438/642,664.ccls.	USPAT	2002/06/24 15:34
7	5184	(spacer and silicide) and gate and (etch\$3)	USPAT	2002/06/24 15:37
8	4160	((spacer and silicide) and gate and (etch\$3) ) and (spacer same etch\$3)	USPAT	2002/06/24 15:37
9	2486	( ((spacer and silicide) and gate and (etch\$3) ) and (spacer same etch\$3) ) and (anisotrop\$5 isotropic\$5)	USPAT	2002/06/24 15:38
10	2258	(( ((spacer and silicide) and gate and (etch\$3) ) and (spacer same etch\$3) ) and (anisotrop\$5 isotropic\$5) ) and ((anisotrop\$5 isotropic\$5) adj2 etch\$3)	USPAT	2002/06/24 15:43
11	2256	(( ((spacer and silicide) and gate and (etch\$3) ) and (spacer same etch\$3) ) and (anisotrop\$5 isotropic\$5) ) and ((anisotrop\$5 isotropic\$5) adj2 etch\$3)) and (silicon polysilicon)	USPAT	2002/06/24 15:40
13	2221	(( (( ((spacer and silicide) and gate and (etch\$3) ) and (spacer same etch\$3) ) and (anisotrop\$5 isotropic\$5) ) and ((anisotrop\$5 isotropic\$5) adj2 etch\$3)) and (silicon polysilicon)) and (metal conduct\$3)	USPAT	2002/06/24 15:41
15	1722	(( (( (( ((spacer and silicide) and gate and (etch\$3) ) and (spacer same etch\$3) ) and (anisotrop\$5 isotropic\$5) ) and ((anisotrop\$5 isotropic\$5) adj2 etch\$3)) and (silicon polysilicon)) and (metal conduct\$3)) and (( anisotrop\$5 adj2 etch\$3) same spacer)	USPAT	2002/06/24 15:44
12	4	coster-walter\$.in. gerritsen-eric.in. basso.marie\$.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/06/24 15:45
14	295	(( (( (( ((spacer and silicide) and gate and (etch\$3) ) and (spacer same etch\$3) ) and (anisotrop\$5 isotropic\$5) ) and ((anisotrop\$5 isotropic\$5) adj2 etch\$3)) and (silicon polysilicon)) and (metal conduct\$3)) and (( isotropic\$5 adj2 etch\$3) same spacer)	USPAT	2002/06/24 16:17